ERRATA: TOWARD CLASSIFYING ELEMENTARY MICROSTRUCTURES IN THIN FILMS BY THEIR SCATTERING RESPONSES

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Received December 14, 1992

The right hand sides of Equations (25a,b) in the subject paper [1] had to be multiplied by 4π , and the correct forms of these equations are as follows:

$$P_{\text{ext}} = (1/2) \text{Real} \left[\sum_m v_m \{ E_{\text{inc}}^*(\mathbf{x}_m) \cdot \mathbf{J}(\mathbf{x}_m) \} \right], \quad (25a)$$

$$P_{\text{ext}} = (\omega/2) \text{Imag} \left[\sum_m \{ E_{\text{inc}}^*(\mathbf{x}_m) \cdot \mathbf{p}_m \} \right]. \quad (25b)$$

I apologize for any problems caused by the typographical errors in the original.

[1] A. Lakhtakia, "Toward classifying elementary structures in thin films by their scattering responses," *Int. J. Infrared Millimeter Waves* **13**, 869-886 (1992).